



Image

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

KIRIL A. PANDELISEV

Serial No.: 09/880,943

Art Unit: 1731

Filed: June 15, 2001

Examiner: C. Lopez

For: HOT SUBSTRATE DEPOSITION OF FUSED SILICA PROCESS AND
APPARATUS

RESPONSE

To the Director of Patents and Trademarks

Sir:

In response to the office action dated January 7, 2004, the applicant provisionally elects Group I claims and traverses the restriction requirement.

Group II claims are directed to the substrate used in making the fused silica products of Group I claims. They are used together and do not have different modes of operation, different functions or different effects.

Examination of all claims is requested.

Respectfully,

James C. Wray, Reg. No. 22,693
Meera P. Narasimhan, Reg. No. 40,252
1493 Chain Bridge Road
Suite 300
McLean, Virginia 22101
Tel: (703) 442-4800
Fax: (703) 448-7397

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